

Title (en)

LOW SURFACE ROUGHNESS POLISHING PAD

Title (de)

POLIERKISSEN MIT GERINGER OBERFLÄCHENRAUHGKEIT

Title (fr)

TAMPON DE POLISSAGE À FAIBLE RUGOSITÉ DE SURFACE

Publication

**EP 3007858 A1 20160420 (EN)**

Application

**EP 14811299 A 20140530**

Priority

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Abstract (en)

[origin: US2014370788A1] The invention provides a polishing pad comprising a polishing pad body comprising a polishing surface, wherein the polishing body comprises pores, and wherein the polishing surface has a surface roughness of about 0.1  $\mu\text{m}$  to about 10  $\mu\text{m}$ .

IPC 8 full level

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CPC (source: EP US)

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